

**REMARKS**

Please consider the attached copy of an article cited in Applicant's previous response, GD Wilk, et al., "High-K Gate Dielectrics: Current Status and Materials Properties Considerations", Journal of Applied Physics, Vol. 89, No. 10, May 15, 2001, in conjunction with Applicant's remarks.

It is requested that should there be any problems with this Amendment, please call the undersigned Attorney at (845) 452-5863.

Respectfully submitted,



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